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Atomic-Scale Characterization of Oxide Interfaces and Superlattices Using Scanning Transmission Electron Microscopy

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Introduction

Over the past several decades, scanning transmission electron microscopy (STEM) has emerged as one of the most robust and versatile platforms for materials characterization.[1–11] Augmented with advanced aberration-correctors, modern electron microscopes enable the simultaneous analysis of crystallography, defects, chemistry, and composition at the atomic-scale. Thin-film oxide heterostructures, which possess intimate coupling among spin, lattice, and orbital degrees of freedom, represent ideal structures for leveraging the power of STEM-based techniques. Precision deposition methods, such as molecular beam epitaxy (MBE) and pulsed laser deposition (PLD), permit the integration of systems with disparate chemical, electronic, and magnetic properties, unlocking emergent phenomena at interfaces.[12–16] Since these structures are typically synthesized in conditions far from equilibrium, it is often difficult to predict their structure and properties *a priori*, necessitating detailed investigation including local STEM probes. The information provided by STEM imaging and spectroscopy can refine first-principles calculations that can in turn be distilled into improved models for the behavior of these novel systems.

STEM techniques, encompassing imaging and diffraction, as well as electron energy loss (STEM-EELS) and energy-dispersive X-ray (STEM-EDS) spectroscopies, are uniquely suited to the analysis of oxide heterostructures and interfaces. These materials generally possess large lattice parameters that are compatible with larger electron probes and their associated higher beam currents, providing enhanced spectroscopic signals. Conveniently, the threshold for beam damage in oxides is much higher than for many other systems,[17] permitting exquisite visualization without significant damage. In addition, the transition metal cations in oxides generally possess sizable X-ray fluorescence yields that facilitate rapid EDS composition mapping. Furthermore, investigations using other X-ray core-level spectroscopies[18] have established a rich theoretical framework to interpret EELS fine structure; experimental efforts are supported by *ab initio* calculations of electronic structure,[19–21] as well as multislice-based image and ionization map simulations.[22–25]

Our understanding of many oxide systems, encompassing applications ranging from multiferroics to spintronics, has been greatly shaped by STEM characterization.[26–28] Using STEM-EELS it is possible to visualize interfacial mixing, which is a candidate mechanism for resolving the polar catastrophe at polar/ nonpolar interfaces.[3,29,30] Electronic reconstructions at interfaces can also be directly measured,[31–33] informing our understanding of two-dimensional electron gas (2DEG) formation. However, while advances in instrumentation have undoubtedly made atomic-scale mapping more commonplace, the interpretation of data is still fraught with challenges. Complex beam–specimen interactions influence STEM-EDS[4,22,23,34–39] and STEM-EELS[22,36,40–43] mapping, leading to delocalization and channeling effects that can complicate interface analysis.[44,45] As more robust and complex modeling packages have been developed, significant strides have been made toward better quantification,[22,34,46] further elevating these techniques as central tools for materials analysis.

In this article we review results from our investigations of key oxide interfaces and superlattices. In particular, we emphasize the high spatial resolution and direct nature of STEM characterization, in contrast to spatially averaged X-ray and ion scattering techniques. In the "Cation Intermixing and Electronic Defects in LCO/STO Superlattices" section we discuss how STEM-EELS may be used to probe cation intermixing and potential sources of interfacial conductivity in model LaCrO$_3$ (LCO)/SrTiO$_3$ (STO) superlattices. The "Interfacial Phase Mapping of LSMO/PZT Magnetoelectric Heterostructures" section describes an approach to map interfacial phases formed by screening of bound charge in magnetoelectric La$_{1-x}$Sr$_x$MnO$_3$ (LSMO)/PbZr$_x$Ti$_{1-x}$O$_3$ (PZT) heterostructures; this study highlights how density functional theory (DFT) calculations may be used to interpret EELS fine structure measurements. The "Interface Characterization of Fe$_2$O$_3$/Cr$_2$O$_3$ Heterostructures for Photocatalysis" section shows how information from both STEM-EELS and STEM-EDS may be combined to improve the design of high-quality Fe$_2$O$_3$/Cr$_2$O$_3$ superlattices for photoelectrochemical water splitting. Finally, the "Challenges to Quantification of Atomic-Scale STEM-EDS Maps" section addresses commonly overlooked limitations of STEM-EDS mapping, illustrating the dramatic effect of sample

preparation on quantification of interfacial mixing. These examples demonstrate the breadth, depth, and complexity of STEM analysis techniques, as well as the unique insight they provide into the properties of oxide superlattices and interfaces.

Cation Intermixing and Electronic Defects in LCO/STO Superlattices

Perovskite oxides are among the most ubiquitous functional materials, owing to their high degree of structural compatibility across different stoichiometries and the wide range of emergent properties at their surfaces and interfaces.[47,48] Extensive work has focused on polar/nonpolar interfaces, particularly in the archetypal LaAlO$_3$ (LAO)/STO system,[49] but models frequently assume a perfectly abrupt interface across which electron transfer occurs. However, previous studies[29,50,51] have found that intermixing is quite common in these materials, indicating that extrinsic defects may play a more important role in mediating interface conductivity than commonly thought. The success of this past work suggests that oxide LCO/STO superlattices consisting of asymmetrically terminated layers may also possess a bulk-like built-in potential gradient.[52,53] While this system is promising for separation of photoexcited electron–hole pairs, the effects of intermixing and cation defects on the potential are poorly described. The most rigorous characterization approaches use Rutherford backscattering (RBS), X-ray absorption spectroscopy, and X-ray photoelectron spectroscopy (XPS), which are either volume-averaged or surface-limited; in contrast, STEM-EELS combines fine structure information and high spatial resolution to locally measure intermixing and electronic defects.[3] A correlative approach, leveraging multiple techniques, is essential to compose more accurate and realistic interface models.

We have examined MBE-grown LCO/STO superlattices on (LaAlO$_3$)$_{0.3}$ (Sr$_2$AlTaO$_6$)$_{0.7}$ (LSAT) (001) substrates.[54] While our previous STEM measurements confirm a polarization induced by the alternation of positively charged [TiO$_2$]^0 | [LaO]$^+$ and negatively charged [CrO$_2$]$^-$ | [SrO]^0 interfaces, we also find evidence for an unexpected conductivity in our samples.[52] To probe the origin of this conductivity, we have conducted extensive STEM-EELS mapping. **Fig. 1A** shows cross-sectional high-angle annular dark field imaging (STEM-HAADF), which reveals a high-quality superlattice consisting of [6 STO/3 LCO]$_{\times 10}$ units. We observe that the film is coherent and epitaxial, with no visible misfit dislocations or secondary phases. **Fig. 1B** shows a composite STEM-EELS map of the integrated La $M_{4,5}$, Cr $L_{2,3}$ and Ti $L_{2,3}$ signals, highlighting the asymmetric termination at each block of the superlattice. **Fig. 1C** and **D** shows line profiles averaged in the film plane for the integrated Ti $L_{2,3}$ edge intensity and Ti L_3 $t_{2g} - e_g$ crystal field splitting, respectively; the latter may be used to investigate potential valence changes, since the transition metal white-lines result from excitations from spin–orbit split $2p_{3/2}$ and $2p_{1/2}$ states to available $3d$ band states.[55] Similarly, **Fig. 1E** and **F** show line profiles averaged in the film plane for the integrated Cr $L_{2,3}$ edge intensity and O K – Cr L_3 edge energy loss separation, respectively. These spectra exhibit measurable Ti and Cr signals in all the layers of the superlattice, although the degree of Cr intermixing is less than that of Ti. We have previously observed sizable Ti outdiffusion in LCO/STO bilayers, which we believe improves the thermodynamic stability of the interface.[56]

In light of this cation intermixing, we next consider potential valence changes and defects associated with this behavior. White-line ratios, though commonly used to estimate local valence, are challenging to compare to results from other groups, owing to subjective differences in background subtraction as well as position-sensitive effects.[40] Instead, we fit the energy loss separation of the Ti L_3 and L_2 edges at each pixel of chemical map, generating the integrated line profile shown in **Fig. 1D**. We observe an average value across the superlattice that falls within the literature range for a Ti^{4+} state; however, the overall profile is tilted toward a slight Ti valence reduction at the film surface, suggesting possible accumulation of excess La. The white-line ratio method is similarly difficult to apply to the Cr $L_{2,3}$ edge because of its overlap with the O K continuum, so we instead consider the Cr L_3 to O K edge separation, which is a known indicator of local valence.[57,58] We again observe that this quantity falls within the expected range of values for a Cr^{3+} state; however, we observe a slight reduction near the interfaces with STO, indicating the possible compensation of Ti^{4+} cations in the nearby STO layers. A comparison to DFT calculations for various defect scenarios shows that excess La can give rise to additional carriers in the STO. Cr substitution for Ti in the STO layer can lead to oxygen vacancy formation due to the instability of octahedrally coordinated Cr^{4+}, suppressing interfacial hole formation and preserving the built-in potential across the superlattice.

Taken together, our results underscore the importance of correlative high-resolution chemical and composition analysis alongside data from volume-averaged techniques. STEM-EELS reveals a "real" interface that stands in stark contrast to the often assumed perfectly abrupt models typically employed in theoretical calculations. The parameters extracted from these measurements can serve as an input for first-principles calculations, refining our understanding of the complex interplay between structure and defects.

Interfacial Phase Mapping Of LSMO/PZT Magnetoelectric Heterostructures

Manganite-based heterostructures represent one of the most widely studied oxide systems because of their intimate coupling among structure, electronic, and magnetic order, which form the basis for spintronic devices.[59–62] Early reports of colossal magnetoresistance (CMR)[63,64] triggered extensive synthesis and characterization efforts throughout the 1990s and early 2000s. The magnetoelectric effect, which heretofore had only been identified in a handful of monolithic compounds (e.g., Cr$_2$O$_3$[65,66] and thin-film BiFeO$_3$ (BFO)[67]), was expanded to encompass a new class of composite magnetoelectrics engineered to couple the
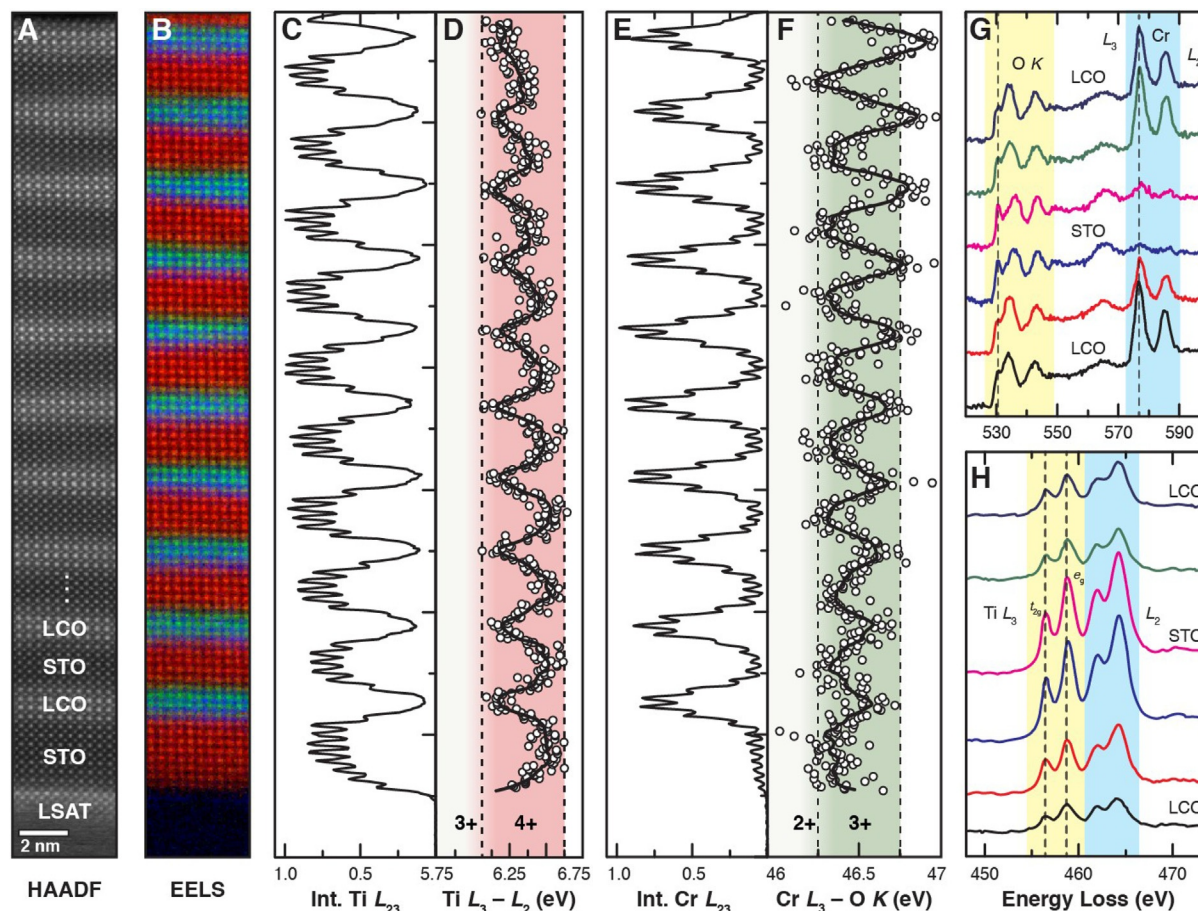
Fig. 1 STEM-EELS analysis of cation intermixing and defects. (A) Cross-sectional STEM-HAADF image of the superlattice acquired during EELS mapping. (B) Composition map of the Ti $L_{2,3}$, Cr $L_{2,3}$, and La $M_{4,5}$ (*red*, *green*, and *blue*, respectively) edges constructed using multiple linear least-squares fitting (MLLS). (C) Line profile of the integrated Ti $L_{2,3}$ edge intensity. (D) Line profile of the Ti L_3 and L_2 edge separation, used to estimate local Ti valence; this profile falls within the bounds of a Ti^{4+} state (marked by the dashed lines). (E) Line profile of the integrated Cr $L_{2,3}$ edge intensity. (F) Line profile of the O K and Cr L_3 edge energy loss separation, used to estimate local Cr valence; this profile falls within the bounds of a Cr^{3+} state (marked by the dashed lines). (G, H) O K/Cr $L_{2,3}$ and Ti $L_{2,3}$ edge spectra, respectively, extracted across the LCO/STO/LCO layers in the middle of the superlattice (*dashed lines* added as a guide to the eye). Reprinted with permission from Comes, R.B; Spurgeon, S. R.; Kepaptsoglou, D. M.; Engelhard, M. H.; Perea, D. E.; Kaspar, T. C.; Ramasse, Q. M.; Sushko, P. V.; Chambers, S. A. Probing the Origin of Interfacial Carriers in SrTiO$_3$ LaCrO$_3$ Superlattices. *Chem. Mater.* **2017**, *29*(3):1147–1155. Copyright 2017 American Chemical Society.

behavior of two or more phases at interfaces.[68] Composite structures based on BaTiO$_3$ (BTO) and PZT soon exhibited magneto-electric coefficients orders of magnitude larger than in single-phase materials.[69]

A wide range of coupling mechanisms has been described in the literature, including charge screening, substrate-induced strain, and magnetic exchange.[59] Much previous work has focused on the presence of interface phases in these structures,[70,71] which are thought to mediate magnetoelectric coupling,[72,73] as well as interfacial magnetization through dead layer formation.[59,60,74–77] Particular attention has been paid to the LSMO/PZT system,[69] which combines the manganite's high ferromagnetic Curie temperature and spin polarization[78,79] with the large charge screening capabilities of the ferroelectric. Vaz *et al.* conducted the first in situ measurements of ultrathin LSMO on PZT using magnetooptical Kerr effect (MOKE) magnetometry, demonstrating coupling mediated by a bound layer of interace charge.[69,80–82] Metallic charge screening by Mn ions is thought to induce changes in the effective local Mn valence, modifying both magnetic moment and spin structure. While these early measurements provided important information about coupling, they were unable to directly probe the interface phases, chemistry, and spatial distribution of Mn valence—all essential parameters needed to develop more complete models of coupling.

Because of the challenges of poling TEM samples *in situ*, we developed an alternative substrate-induced self-poling technique.[83,84] This method takes advantage of the electrostatic boundary conditions of the substrate, which have been shown to induce spontaneous unidirectional polarization of PZT.[84–88] A ~2 nm La$_{0.7}$Sr$_{0.3}$MnO$_3$ buffer layer was first deposited on STO (001) using PLD, followed by a ~37 nm-thick PbZr$_{0.2}$Ti$_{0.8}$O$_3$ layer and a second ~19 nm-thick LSMO layer. This approach nominally produces two different interface charge states in a single sample, with the top layer in a hole charge depletion state and the bottom layer in an accumulation state.

STEM-EELS allows us to measure spatially resolved core loss spectra to probe local bonding and Mn valence, which we can then relate to the adjacent PZT polarization.[32,55,89] Fig. 2A shows a cross-sectional STEM-HAADF image of the heterostructure, overlaid with a line scan along which O K edge spectra were extracted in Fig. 2B. The fine structure of the edge arises from the first-order transition of electrons from the O $1s$ to $2p$ states; the three features labeled (A–C) are associated with hybridized states of O $2p$ states with Mn $3d$, La $5d$/Sr $4d$, and Mn $4sp$ bands, respectively.[55] Clear shifts in the spectral weight and position of the fine structure features are evident across the LSMO/PZT interfaces, indicating local Mn valence changes. Fig. 2C shows the Mn $L_{2,3}$ edge, which has been aligned to the commonly used position of the O K edge near 532 eV[55]; the guides to the eye mark a distinct shift to lower L_3 energy onset in the vicinity of both interfaces, denoting a Mn valence reduction. While this procedure is not susceptible to energy drift errors, it is preferable to measure the absolute energy of the Mn $L_{2,3}$ edge relative to a known internal reference, such as the zero-loss peak or C K edge if possible, since the shape of the O K edge can change greatly depending on the compound.

Fig. 3A and B show plots of the O K pre- to main-peak energy separation ($\Delta E_{O(b-a)}$), which is independent of energy calibration. Both interfaces exhibit a decrease from a bulk value of 5.5–6 to < 1.0 eV near the interface, but the bottom LSMO shows this drop over 1 nm versus 2.5–3 nm for the top interface. While these separations are in good qualitative agreement with standards investigated by Varela et al.,[55] direct, quantitative comparison to samples measured on other microscopes not advised because of differences in peak fitting and microscope parameters. Instead, we compare our values to DFT calculations to estimate the local variation in Mn doping; this, in turn, may be related to the bulk LSMO phase diagram to map the local phases present at both PZT interfaces. Fig. 3C and D shows the resulting spatially resolved LSMO phase diagram in the vicinity of the PZT. We find that the Mn valence corresponds to the expected bulk La$_{0.7}$Sr$_{0.3}$MnO$_3$ (Mn$^{3.3+}$) doping up to three lattice planes away from the bottom interface, where it drops by ~ 0.15 over a nanometer. On the other hand, the top interface exhibits a larger ~ 0.26 drop over a 2.5–3 nm region, indicating an asymmetric coupling. Comparison to the bulk LSMO phase diagram[90] shows that the bottom interface region is almost uniformly ferromagnetic and metallic to the PZT interface, while the top region transitions to a broad paramagnetic- insulating phase at the interface, which can explain the observed asymmetry. This behavior agrees quite well with a model that had been suggested for LSMO/BTO[91] but had never been applied to LSMO/PZT. These first-of-their-kind measurements of local phase gradients show that longer charge screening lengths can actually be the byproduct of an electrostatic doping-induced phase transition.

Interface Characterization of Fe$_2$O$_3$/Cr$_2$O$_3$ Heterostructures for Photocatalysis

In the "Cation Intermixing and Electronic Defects in LCO/STO Superlattices" section we discussed how STEM-EELS provides detailed insight into conductivity and the preservation of a built-in potential in photoactive superlatttices. Hemtatite (α-Fe$_2$O$_3$) is another system that has received considerable attention because of its abundance, stability, and suitable bandgap for photocata-lysis.[92] Nanostructured hematite-based systems show promise for facilitating separation of electron–hole pairs, while enhancing the effective surface area available for photochemistry.[93] The superlattice layering of Fe$_2$O$_3$ with Cr$_2$O$_3$ has been shown to exhibit favorable band offset properties, leading to a sizable electrostatic potential, which can further improve the separation of electron–hole pairs.[94–96] However, to build and maintain this potential, we must strictly control layer termination, composition, and intermixing, which may be checked by the use of STEM probes, in conjunction with volume-averaged techniques.
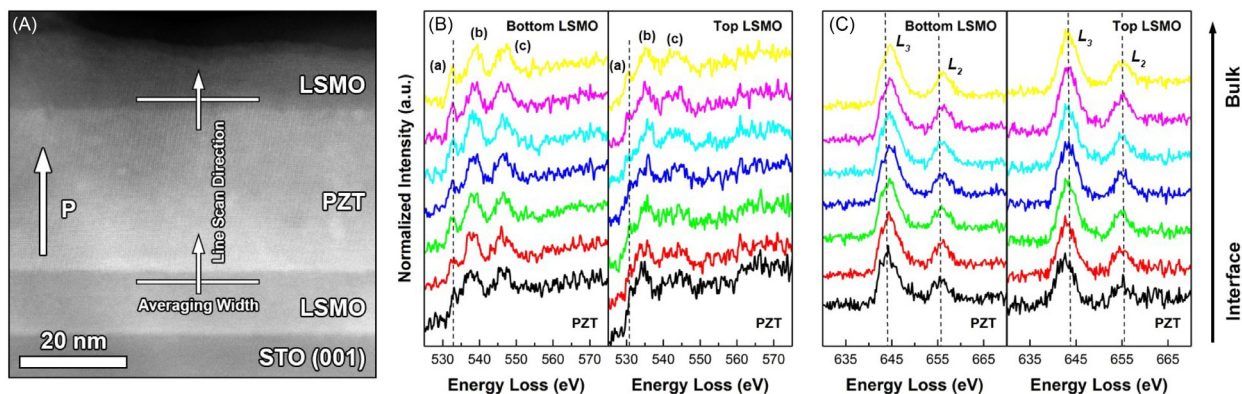

Fig. 2 Structural and chemical mapping of the heterostructure. (A) Cross-sectional STEM-HAADF image of the film structure, with the direction of ferroelectric polarization and linescan paths indicated. (B) Power-law subtracted EEL spectra corresponding to the O K edge, collected at every lattice plane beginning at the LSMO/PZT interface. (A), (B), and (C) correspond to the pre-, main-, and secondary-peak features, respectively. (C) Power-law subtracted EEL spectra corresponding to the Mn $L_{2,3}$ edge. Reprinted with permission from Spurgeon, S. R.; Balachandran, P. V.; Kepaptsoglou, D. M.; Damodaran, A.R.; Karthik, J.; Nejati, S.; Jones, L.; Ambaye, H.; Lauter, V.; Ramasse, Q. M.; Lau, K. K. S.; Martin, L. W.; Rondinelli, J. M.; Taheri, Mi-T. L. Polarization Screening-Induced Magnetic Phase Gradients at Complex Oxide Interfaces. *Nat. Commun.* **2015**, *6*, 6735. Copyright 2015. Rights managed by Nature Publishing Group.
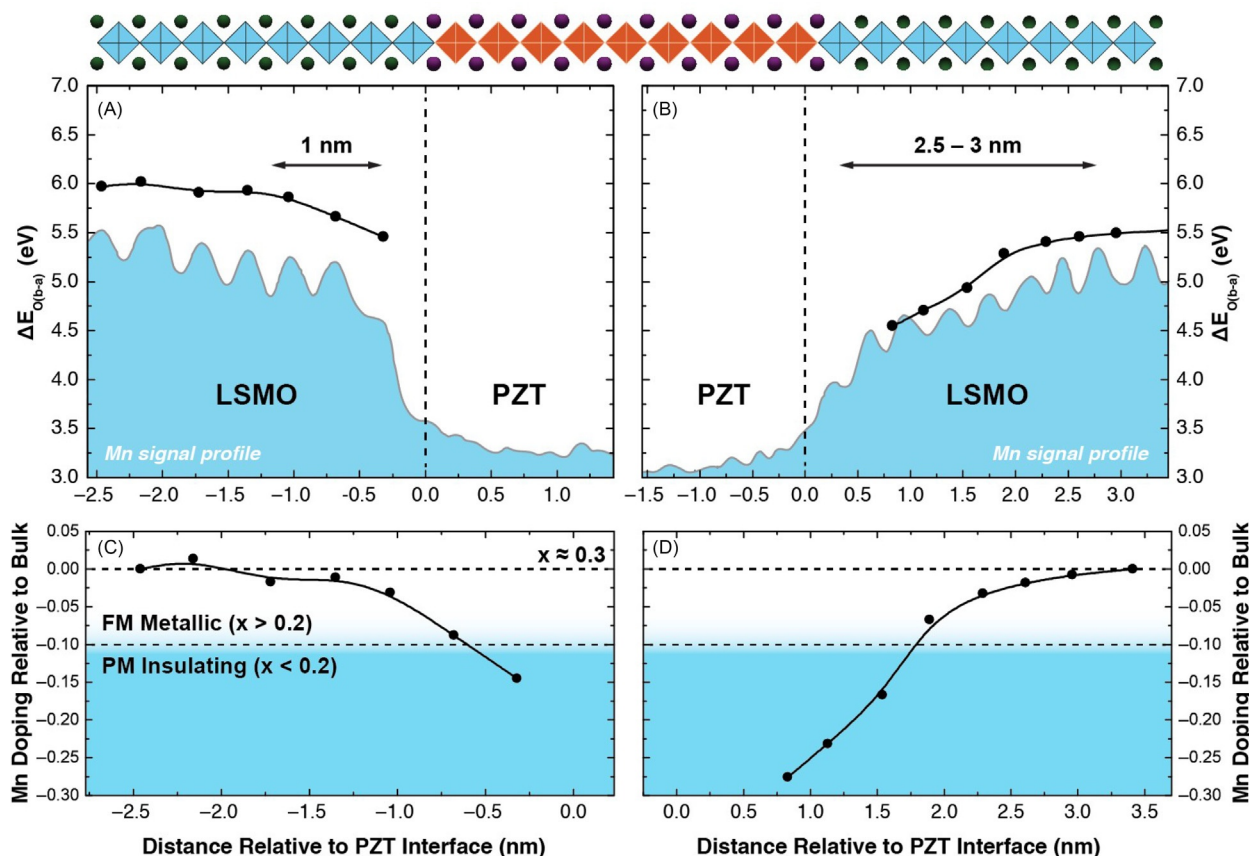
Fig. 3 Spatially resolved LSMO phase diagram. (A, B) show the O *K* pre- to main-peak separation ($\triangle E_{O(b-a)}$) in the vicinity of the PZT interface for the bottom and top LSMO layers, respectively, overlaid with an illustration of the heterostructure. (C, D) Map of local Mn doping relative to bulk LSMO as a function of position normal to the LSMO/PZT interface for the bottom (A) and top (B) LSMO layers. The marked boundaries of the associated magnetic and electronic phases are estimated from the bulk LSMO phase diagram.[90] Adapted with permission from Spurgeon, S. R.; Balachandran, P. V.; Kepaptsoglou, D. M.; Damodaran, A.R.; Karthik, J.; Nejati, S.; Jones, L.; Ambaye, H.; Lauter, V.; Ramasse, Q. M.; Lau, K. K. S.; Martin, L. W.; Rondinelli, J. M.; Taheri, Mi-T. L. Polarization Screening-Induced Magnetic Phase Gradients at Complex Oxide Interfaces. *Nat. Commun.* **2015**, *6*, 6735. Copyright 2015. Rights managed by Nature Publishing Group.

We have synthesized Fe_2O_3/Cr_2O_3 superlattices on Al_2O_3 (0001) substrates using MBE; careful control of the deposition ensures that each bilayer composition provides the largest conduction and valence band offsets, resulting in a large built-in electric field across the superlattice.[57] **Fig. 4A** shows a STEM-HAADF image of the overall film structure, inset with high magnification views of the film–substrate interface and superlattice. We observe that the interface with the Al_2O_3 substrate is coherent, uniform, and defect-free. Furthermore, all the layers of the superlattice are preserved, albeit with some undulation due to the large lattice mismatch of $a_{Cr_2O_3} - a_{Al_2O_3} / a_{Al_2O_3}$=4.2%. While the STEM-HAADF image shows a clear contrast between the film and substrate, the similar atomic number (Z) of the film layers necessitates the use of spectroscopy to directly resolve the superlattice components. Although STEM-EDS offers poorer energy resolution ($\sim$10 eV) than STEM-EELS (<0.1 eV), the technique is able to measure a wide range of ionization energies simultaneously, making it well-suited to the analysis of metal-oxides.[98] **Fig. 4B** shows a composite STEM-EDS map of the Al *K*, Fe *K*, and Cr *K* edges; this map confirms the overall composition and geometry of the film layers. For even more detail, we have acquired a STEM-EELS line scan from the HAADF image in **Fig. 4C**; by using a line scan (instead of a map) we are able to reduce the damage to the specimen, thereby preserving the integrity of the electronic fine structure. **Fig. 4D** shows the power law background-subtracted integrated Fe $L_{2,3}$, Cr $L_{2,3}$, and Ti $L_{2,3}$ edge signals, normalized to their concentration in the Cr_2O_3 buffer layer. The profile confirms the superlattice configuration in agreement with the STEM-EDS results, but the added spatial resolution shows that there is intermixing over $\sim$0.5 nm near the bottom and top of the superlattice.

Turning to the electronic fine structure, we next explore systematic changes in the energy separation of the O *K* and Cr L_3 edges, as was done in "**Cation Intermixing and Electronic Defects in LCO/STO Superlattices**" section; using this approach, we avoid deconvolving the tail of the O edge from the onset of the Cr edge. **Fig. 4E** shows the measured energy separation, overlaid with range of values corresponding to a Cr^{3+}-like state extracted from the literature.[58] We observe a slight increase toward more Cr^{4+}-like character near the bottom of the superlattice, but the overall valence falls squarely within the bounds of the Cr^{3+}-like state; this behavior may reflect intermixing with the Fe layer, as is evident in **Fig. 4C**. To gain insight into the valence of the Fe, we have conducted measurements of the Fe$L_{2,3}$ white-line ratio according to the method of van Aken *et al.*,[97] as shown in **Fig. 4F**. Although
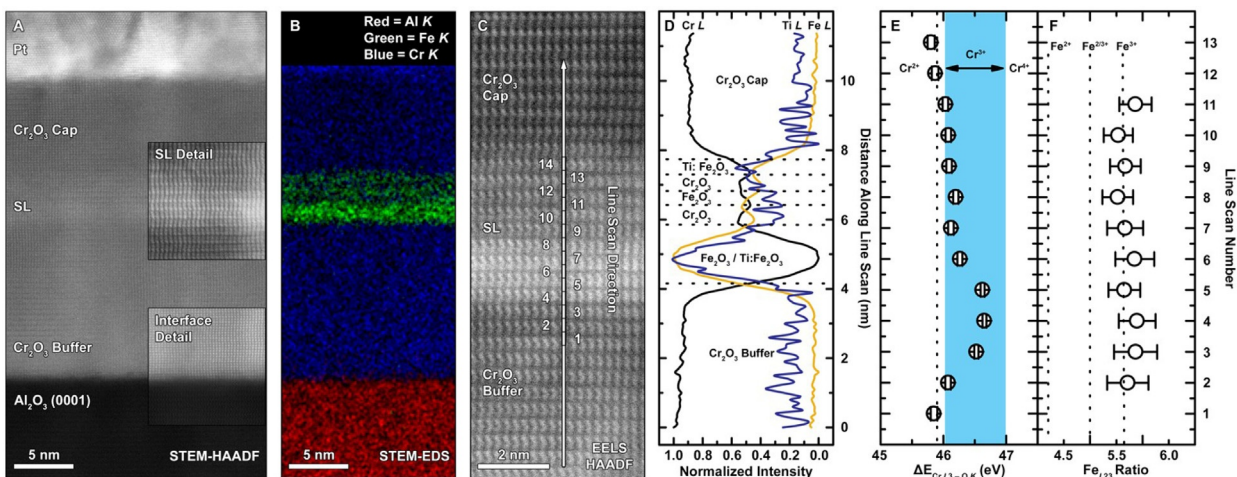
Fig. 4   STEM analysis of the Fe_2O_3/Cr_2O_3 superlattice. (A) Cross-sectional STEM-HAADF image of the film, inset with high magnification images of the film-substrate interface and superlattice. (B) STEM-EDS map of the Al K, Fe K, and Cr K peaks. (C) Radial-difference filtered STEM-HAADF image of the region used for EELS measurements. A line scan has been extracted and subsequent spectra have been integrated in the marked windows. (D) STEM-EELS integrated signal profiles extracted from the line scan region in C. The profiles were processed using principal component analysis, then background subtracted, and normalized to the Cr_2O_3 buffer layer. (E) O K and Cr L_3 edge energy loss separation, used to estimate local Cr valence; these points fall within the bounds of a Cr^{3+} state (marked by the *shaded region*). The error bars correspond to the standard error of Gaussian fits to the edge. (F) Fe $L_{2,3}$ white-line ratios calculated according to the method of van Aken et al.[97] The *dashed lines* correspond to the range of literature values. Reprinted with permission from Kaspar, T. C.; Schreiber, D. K.; Spurgeon, S. R.; McBriarty, M. E.; Carroll, G. M; Gamelin, D. R.; Chambers, S. A. Built-In Potential in Fe_2O_3-Cr_2O_3 Superlattices for Improved Photoexcited Carrier Separation. *Adv. Mater.* **2016**, *28*(8), 1616–1622. Copyright 2016 John Wiley and Sons.

we again emphasize that quantitative comparison to other results the literature is difficult, owing to differences in background subtraction and peak fitting methodologies, we find that the ratio falls within the range of values expected for an Fe^{3+}-like state.[97,99]

This study confirms that it is possible to synthesize high-quality Fe_2O_3/Cr_2O_3 superlattices using MBE. While STEM-EELS indicates some intermixing near the top and bottom of the superlattice, the overall chemistry of the Fe and Cr layers is preserved. In conjunction with XPS and related characterization,[57] we find that the favorable band alignment and enhanced photoconductivity of these materials may facilitate improved photoelectrochemical water splitting.

Challenges to Quantification of Atomic-Scale STEM-EDS Maps

As has been demonstrated in this article, chemical mapping using STEM-EELS and STEM-EDS offers several advantages compared to nonspectroscopic imaging. In particular, these techniques are directly sensitive to the elemental composition of a sample, whereas STEM-HAADF is less readily quantified. Furthermore, the enhanced energy resolution in EELS allows the operator to directly interrogate electronic fine structure and properties such as valence and bonding. However, strong interactions between the incident electron beam and lattice can lead to serious artifacts that preclude straightforward analysis of atomic-scale chemical maps. Effects such as beam broadening and channeling[38] are particularly troublesome along low-order zone axes, resulting in coupling between the probe and atomic columns.[35] Thermally scattered electrons can influence the ionization signal in both STEM-EDS and STEM-EELS,[36] as well as introduce image contrast reversals in STEM-EELS due to off-column probe channeling.[38,42] Although first-principles calculations have been able to model the Bremsstrahlung background in STEM-EDS,[98] resulting in a simpler signal integration process,[37] channeling and probe broadening through the specimen still make it difficult to accurately quantify unknown interfaces.[100]

To better understand sources of error in atomic-scale STEM-EDS mapping of interfaces, we have characterized a model heterostructure that shows potential use for a transparent, perovskite-based p–n junctions.[101] This system consists of a 30 nm-thick $La_{0.88}Sr_{0.12}CrO_3$ (p-type LSCO) thin-film deposited onto a 0.1 wt.% Nb:STO (001) (n-type Nb:STO) substrate using MBE.[102] The wedge-shaped sample shown in **Fig. 5** was prepared using a modified focused ion beam lift out procedure to produce a range of cross-section thicknesses. STEM-EDS maps were subsequently acquired from different regions spanning 28, 33, 50, 66, 70, and 75 nm-thick, according to zero-loss peak measurements.

Fig. 6A shows a representative cross-sectional STEM-HAADF image of the heterostructure. The sample displays excellent epitaxy between the film and substrate, with no obvious defects or misfit dislocations.[56] The contrast clearly changes across the film–substrate interface, resulting from the differing atomic numbers of the cation species, as well as a varying background contribution that is known to depend on sample thickness[103] and oxygen content. Even in the case of atomically abrupt interfaces, a finite sample thickness gives rise to an intermediate background different from either component of the junction.[103] While zero-loss
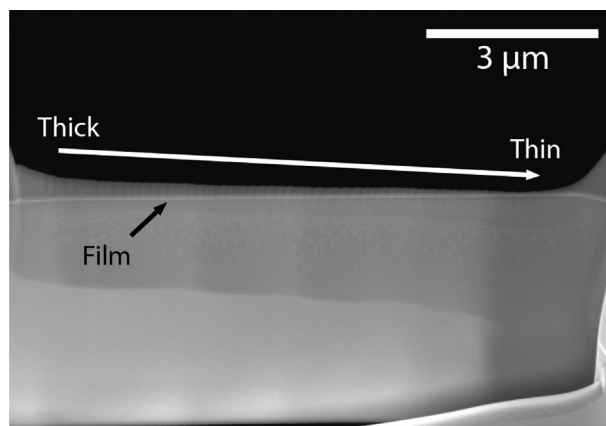
Fig. 5 STEM sample preparation. Cross-sectional secondary electron image of the polished lift out, with the gradient from thick to thin foil regions marked by the *arrow*. The bright horizontal band corresponds to the location of the film–substrate interface.
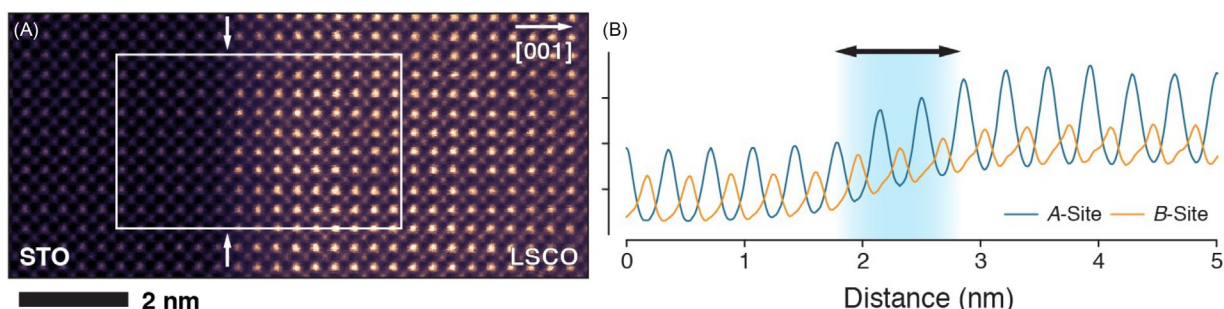

Fig. 6 LSCO/STO interface characterization. (A) Representative cross-sectional STEM-HAADF image of the LSCO/STO interface taken along the [100] zone-axis. (B) Average of 10 *A*- and *B*-site profiles taken across the interface, with the shaded region indicating the interface position.

measurements of the sample show minimal thickness fluctuations across the interface, we still observe a sloping background variation, as shown in the extracted line profile in **Fig. 6B**. Such a background hinders accurate quantification of intermixing, since it is possible to define the interface width in several ways: (1) relative to the changing background, (2) relative to the signal after background subtraction, or (3) relative to the column ratios within each layer.[104]

Since the cation species are similar in this compound, STEM-EDS can provide a more directly interpretable measurement of the interdiffusion of each species. **Fig. 7A** and **B** shows composite STEM-EDS maps and corresponding averaged line profiles for Sr L_α (1.806 kV), La L_α (4.650 kV), Ti K_α (4.508 kV), and Cr K_α (5.412 kV) edges taken from $\sim$33 and $\sim$75 nm-thick regions of the sample, respectively. We define the apparent interface width (δ) as the difference of 90% and 10% of the signal maxima from a logistic fit to either side of the interface. These profiles clearly reveal some intermixing, particularly of Ti and Cr, as we have observed in other samples.[54] Moreover, there are noticeable differences in the interface width between the two regions, as well as a higher background in the thicker part of the foil. We have repeated this same procedure for a range of foil thicknesses, as shown in **Fig. 7C**. We observe a clear trend toward more diffuse interfaces in thicker samples, ranging from 2–5 unit cells of artificial broadening depending on the species. We find that δ_{La} increases to $\sim$1.8 nm moving from 28 to 75 nm-thick regions; similarly, δ_{Sr} and δ_{Cr} increase by $\sim$0.86 and $\sim$0.96 nm, respectively, while δ_{Ti} increases by $\sim$0.87 nm. To confirm that these changes are not due to the presence of substrate steps, we have conducted atomic force microscope measurements of the STO surface prior to growth; our measurements show that at most only one step is present along the beam direction for the measured foil thicknesses, ruling out steps as a source of the artificial interface broadening. These results indicate that interface measurements strongly depend on sample preparation, as well as the choice of ionization edge, and that each exhibits different trends.

We have conducted multislice ionization simulations (described in reference 101) that confirm a consistent trend toward artificially broadened interfaces in thicker regions. We find that a foil thickness of only 40–50 nm is sufficient to introduce multiple unit cell measurement errors arising from complex beam channeling effects, as well as the delocalization character of each edge. We strongly recommend that rigorous sample preparation routines be employed to achieve the thinnest foils, with the best results being obtained below 25–30 nm. However, at these thicknesses it is difficult to achieve a reasonable ionization signal, necessitating the use of lower accelerating voltages (increasing the ionization cross-section), large-area EDS detectors, or advanced drift correction routines to enhance signal-to-noise.[105,106] Regardless, our results suggest that many atomically resolved maps may
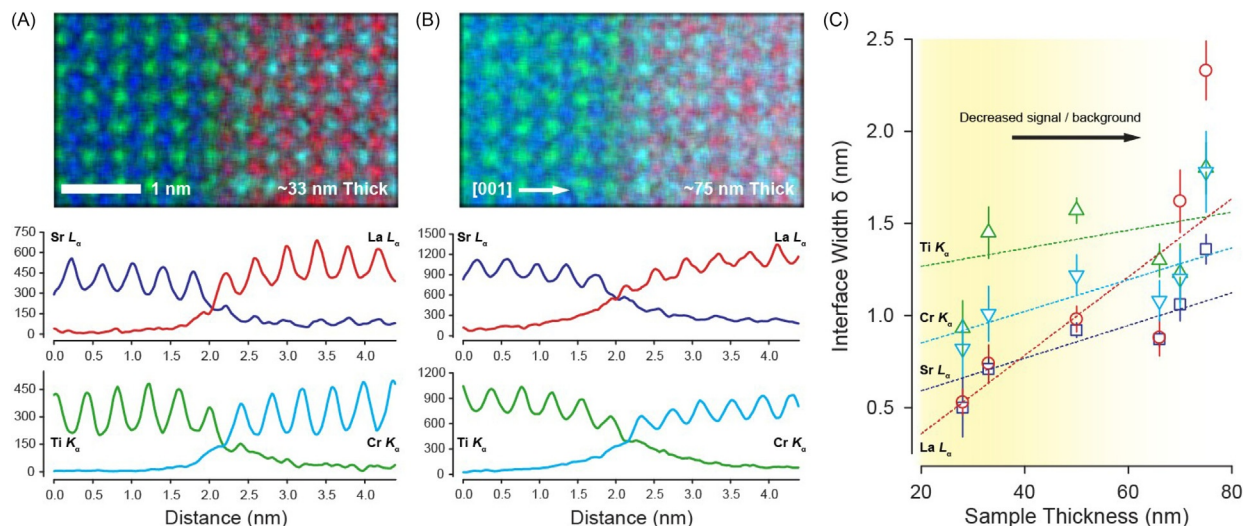
Fig. 7 Thickness dependence of STEM-EDS mapping. (A-B) Unfiltered composite STEM-EDS maps and corresponding *A*- and *B*-site net X-ray count line profiles for ~33 and ~75 nm-thick LSCO/STO interfaces, respectively. The line profiles have been averaged in the plane of the maps. (C) Interface width as a function of sample thickness for each species. Adapted with permission from Spurgeon, S. R.; Du, Y.; Chambers, S. A. Measurement Error in Atomic-Scale Scanning Transmission Electron Microscopy—Energy-Dispersive X-ray Spectroscopy (STEM- EDS) Mapping of a Model Oxide Interface. Microsc. Microanal. 2017, 23 (3), 513–517. Copyright 2017 Microscopy Society of America.

not be taken at face value and that accompanying theory calculations are needed to fully understand complex beam–specimen interactions.

Concluding Remarks

In this article we have illustrated the range of STEM techniques and their application to a variety of different oxide interfaces and superlattices. These techniques offer unparalleled spatial resolution and a panoply of structural, chemical, and compositional information that can greatly inform models for the behavior of oxides. While many of these methods are mature and well understood, there are still areas for improvement, particularly in the realm of image quantification and interpretation. Furthermore, we emphasize that STEM is often well complemented by other established techniques, such as X-ray diffraction and XPS, as well as emerging techniques, such as atom probe tomography, that can provide correlative volume-averaged information.[107,108] Using these tools we can develop a more complete and realistic understanding of functional interfaces needed to unlock next-generation materials and devices.

Acknowledgments

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